

Notice of References Cited	Application/Control No. 10/670,256	Applicant(s)/Patent Under Reexamination MIYATA, HIROKATSU	
	Examiner William P. Fletcher III	Art Unit 1762	Page 1 of 1

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	U	Miyata et al., Alignment of Mesoporous Silica on a Glass Substrate by a Rubbing Method, Chem. Mater. 1999, 11, 1609-1614. Published on Web 5/11/1999.
	V	Definition of 'polyimide' from Alger's Polymer Science Dictionary, 2nd Edition, Copyright 1989 by Chapman & Hall, 1997 Mark Alger, page 420.
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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